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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

CHEVALIER et al

Atty. Ref.: 5215-2; Confirmation No. 7840

Appl. No. 10/557,695

TC/A.U. 1716

Filed: December 22, 2005

Examiner: Alejandro Mulero, Luz L

For: A HIGH DENSITY PLASMA REACTOR

\* \* \* \* \*

April 27, 2011

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**INTERVIEW SUMMARY STATEMENT**

In response to the Interview Summary mailed on April 7, 2011, the undersigned confirms that the Interview Summary provides a reasonable summary of the substance of the most recent telephone discussions with the Examiner on April 6, 2011. At that time, the undersigned discussed various options with the Examiner, including the possible amendment of the claims or the filing of an Appeal Brief based upon the existing claims that the applicant and the undersigned believe are patentable over the cited art of record for at least the reasons presented in the After Final Amendment filed on February 7, 2011.

Applicant is currently considering whether to proceed with the appeal or amend the claims to even further distinguish the invention over the cited art of record.

The undersigned thanks the Examiner for the courtesies extended in the telephone discussions to date.

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Respectfully submitted,

**NIXON & VANDERHYE P.C.**

By: \_\_\_\_\_

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